

Electronic Supporting Information

Exfoliation of WS₂ in Semiconducting Phase using a Group of Lithium Halides: a New Method of Li Intercalation

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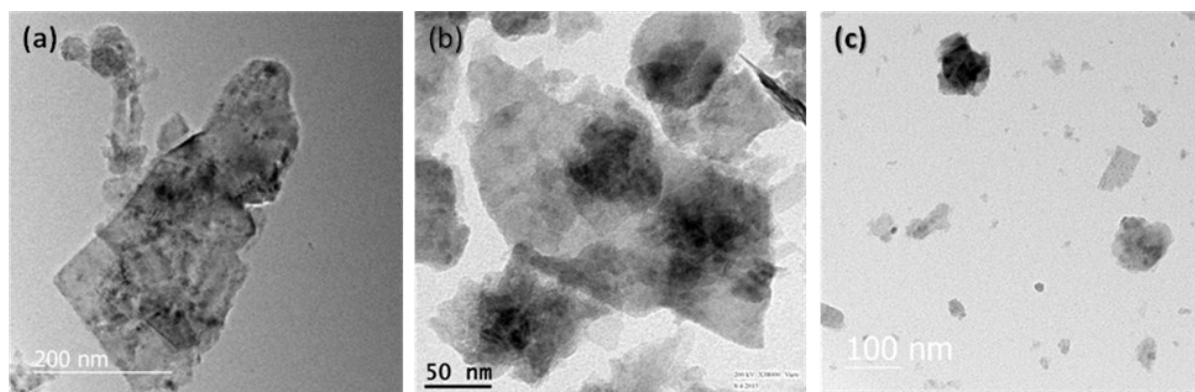


Figure S1: TEM images of few layer WS₂ flakes collected at (a) below 1000 rpm (WS₂ (1K), average size ≥ 500 nm); (b) below 2000 rpm (WS₂ (2K), average size ~ 300 nm); (c) collected above 3000 rpm (WS₂ (3K), average size ≤ 100 nm).

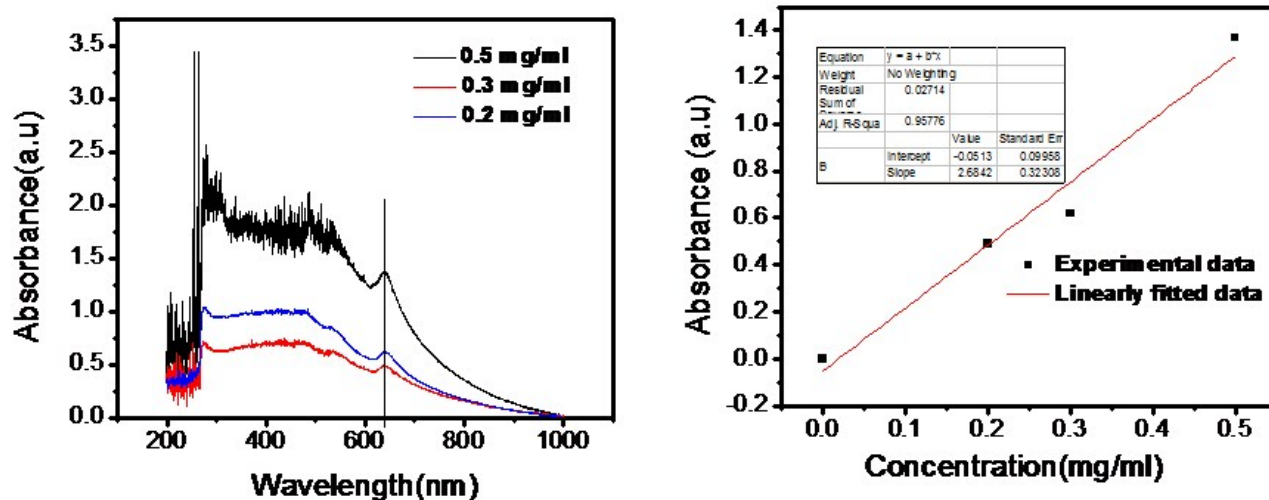


Figure S2: (a) Absorbance of WS₂ in DMF at 640 nm and (b) its corresponding absorbance with concentration. From the fitted curve slope, absorption coefficient is 2.68 ml mg⁻¹ cm⁻¹ at 640 nm.

Table S1

WS ₂ :Alkali halide (mole ratio)	LiCl, (4h sonication at the first step)
(1:1)	~5.5 mg / mL
(2:1)	~2 mg/ml
(1:2)	~1 mg/ml
1:0	0

$$\sigma_{sl} = \sigma_{solid} + \sigma_{liquid} - 2 \left(\sqrt{\sigma_{solid}^d \sigma_{liquid}^d} + \sqrt{\sigma_{solid}^p \sigma_{liquid}^p} \right)$$

$$= \sigma_{solid}^d + \sigma_{solid}^p + \sigma_{liquid}^d + \sigma_{liquid}^p - 2\left(\sqrt{\sigma_{solid}^d \cdot \sigma_{liquid}^d} + \sqrt{\sigma_{solid}^p \cdot \sigma_{liquid}^p}\right)$$

Where σ_{solid} and σ_{liquid} are the surface tension of the solid and solvent, respectively and p indicates the polar component and d represents the dispersive component of surface tension. σ_{sl} is the interfacial surface tension between liquid solvent and solid. For efficient exfoliation σ_{sl} should be minimised.¹ Thus the polar and dispersive part of the surface tension played an important role in liquid phase exfoliation. Generally the solvents having surface tension value around 40 mN/m (DMF-37.1 and for Hexane-18.43 mN/m) are good exfoliating agent for exfoliation,² because those solvents have lower interfacial surface tension. The ratio of σ_{solid}^p to σ_{solid}^d of WS₂ is around 0.563 and surface tension is around 40 mN/m.² The interfacial surface tension is calculated for WS₂ in DMF as 0.86 mN/m and that of WS₂ in hexane as 15.5 mN/m.

The solvents which have minimum interfacial surface energy are a good solvent for liquid exfoliation.

As we know that total surface tension σ_{solid} is equal to the sum of polar and dispersive components of the surface tension. So we can write

$$\sigma_{solid} = \sigma_{solid}^d + \sigma_{solid}^p \dots\dots\dots (2)$$

Now total surface tension of WS₂ is 40 mN/m, so we can write,

$$\sigma_{solid}^{WS2} = \sigma_{solid}^{d(WS2)} + \sigma_{solid}^{p(WS2)} = 40 \dots\dots\dots (3)$$

Again we know that the ratio of σ_s^p and σ_s^d of WS₂ is around 0.563, so

$$\sigma_{solid}^{p(WS2)} / \sigma_{solid}^{d(WS2)} = 0.563 \dots\dots\dots (4)$$

From equation (2) we can calculate,

$$\sigma_{solid}^{d(WS_2)} - \sigma_{solid}^{p(WS_2)} = 11.18 \dots\dots\dots(5)$$

By solving equation (1) and (3) we get, $\sigma_{solid}^{p(WS_2)} = 14.91$ and $\sigma_{solid}^{d(WS_2)} = 25.09$

So using this value we calculate the interfacial surface tension of different solvents which is shown in following table S2. The exfoliation yield is also tabulated for comparison.

Table: S2

Solvent	Surface Tension (mN/m) (σ)	Polar Component of Surface Tension (mN/m) (σ_{liquid}^p)	Dispersive Component of Surface Tension (mN/m) (σ_{liquid}^d)	Interfacial Surface Tension between WS ₂ and solvents (mN/m) (σ_{sl})	Experimental Yield (mg/ml) LiI, 30 min sonication 1st step
DMF	36.50	11.30	25.20	0.26	4.81
EtOH	23.70	4.40	19.30	3.52	0.18
IPA:Water (1:1)	25.13	8.17	16.96	1.81	1.1
Water	72.75	50.65	22.10	10.71	0
Hexane	18.43	0	18.43	15.499	0
Acetone	23.30	16.50	6.80	5.82	0
NMP	40.79	11.58	29.21	0.59	2.5

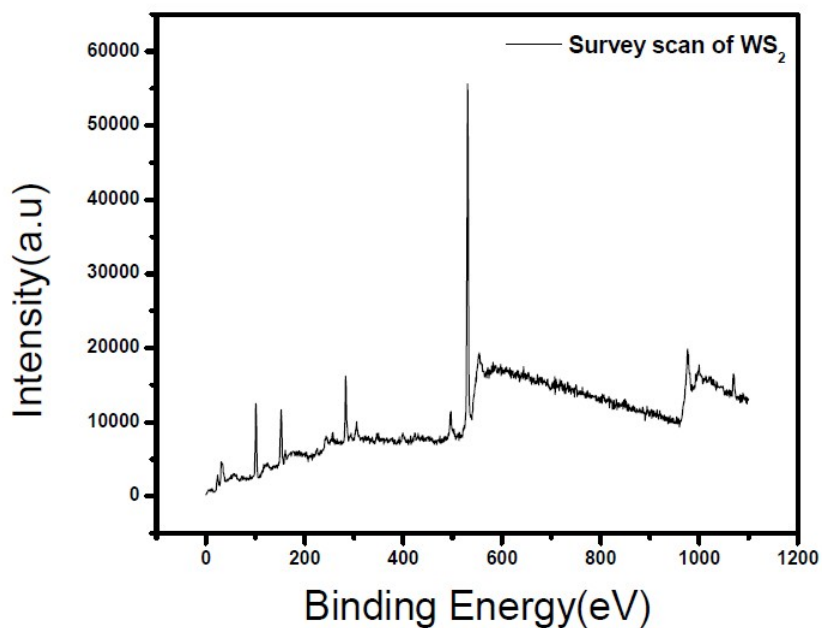
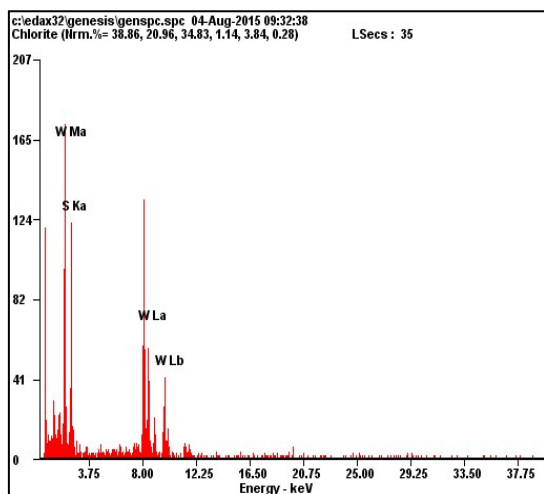


Figure S3: XPS Survey scan of WS₂ nanosheet



<i>Element</i>	<i>Wt %</i>	<i>At %</i>
<i>W M</i>	69.53	31.04
<i>S K</i>	26.20	67.05
<i>W L</i>	04.28	01.91

Figure S4: EDAX spectra of WS₂ nanosheet

¹ Shen, J.; He, Y.; Wu, J.; Gao, C.; Keyshar, K.; Zhang, X.; Yang, Y.; Ye, M.; Vajtai, R.; Lou, J.; Ajayan, P. M. Liquid Phase Exfoliation of Two-Dimensional Materials by Directly Probing and Matching Surface Tension Components. *Nano Lett.* **2015**, *15*, 5449–5454.

² Cunningham, G.; Lotya, M.; Cucinotta, C. S.; Sanvito, S.; Bergin, S. D.; Menzel, R.; Shaffer, M. S. P.; Coleman, J. N. Solvent Exfoliation of Transition Metal Dichalcogenides: Dispersibility of Exfoliated Nanosheets Varies Only Weakly between Compounds. *ACS Nano* **2012**, *6*, 3468–3480.